

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L3	11249	atomic layer deposition or ald or ale or atomic layer epitaxy	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/06/14 09:14
L4	78	3 same (argon with purge)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/06/14 09:14
S1	267	(titanium tetrachloride "ticl.sub.4") same (ammonia or "NH.sub.3")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/06/13 17:14
S2	62	S1 and (atomic layer deposition or ald)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/06/13 17:20
S3	198	(titanium tetrachloride "ticl.sub.4") near25 (ammonia or "NH.sub.3")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/06/13 17:15
S5	48	S3 and (atomic layer deposition or ald)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/06/13 17:15
S6	31	S2 and (argon or ar)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/06/13 17:20